Application/Control No.	Applicant(s)/Patent under Reexamination	ınder	
10/651,049	GONTIN ET AL.		
Examiner	Art Unit		
Marissa J. Detschel	2877		

SEARCHED					
Class	Subclass	Date	Examiner		
356	488	8/1/2005	MJD		
356	494	8/1/2005	MJD		
356	512	8/1/2005	MJD		
356	521	8/1/2005	MJD		
250	237G	8/1/2005	MJD		
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INTERFERENCE SEARCHED					
Class	Subclass	Date	Examiner		
356	521 Pubs	8/2/2005	MJD		
356	512 Pubs	8/2/2005	MJD		
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SEARCH NOT (INCLUDING SEARCH S)
	DATE	EXMR
All of 356 and wavefront and second adj grating	8/1/2005	MJD
All of 356 and wavefront and reticle asj stage and wafer adj stage	8/1/2005	MJD
All of 356 and lateral adj shearing adj interferometry	8/1/2005	MJD
All of 356 and rough adj grating	8/2/2005	MJD
All of 356 and random\$ near grating and parallel	8/2/2005	MJD
All of 356 and nonuniform adj grating and parallel	8/2/2005	MJD